

Impact of Molecular Dynamics (MD) Simulations in Materials Research

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Contributions from D. K. Ward and M. E. Foster are greatly appreciated

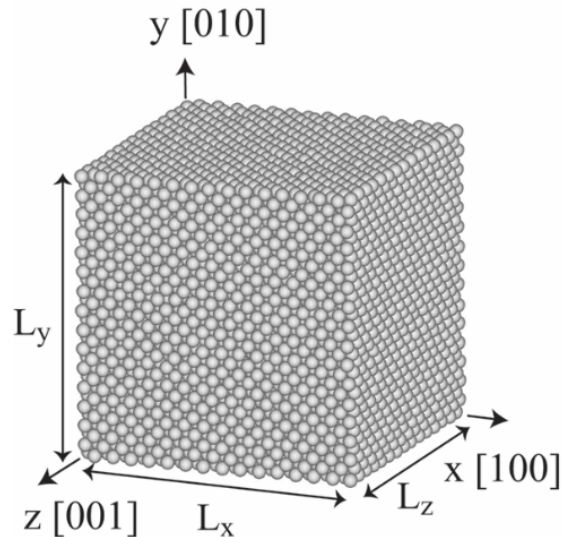
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Outline

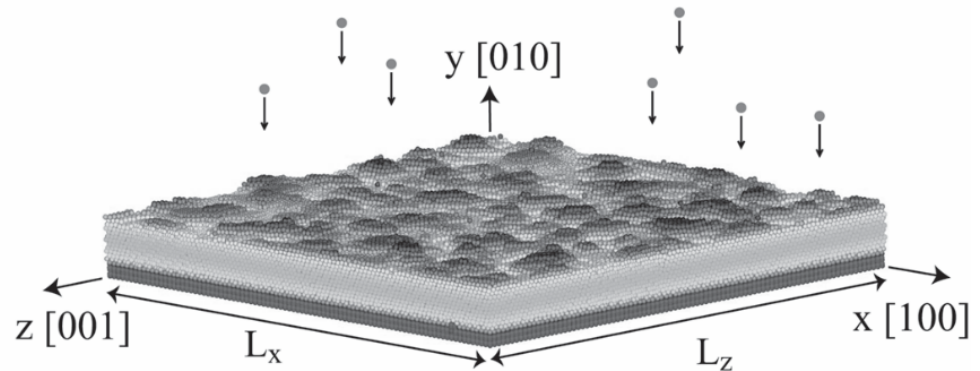
- ❑ Molecular dynamics simulation methods
- ❑ Graphene
- ❑ Giant magnetoresistive multilayers
- ❑ CdTe/CdS solar cell films
- ❑ $\text{In}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$ solid state lighting films
- ❑ Misfit dislocation theory
- ❑ Al-Cu bond order potential
- ❑ $2\text{H} \Rightarrow \text{H}_2$ chemical reaction
- ❑ CdZnTe radiation detection materials

MD Simulation Methods

(a) bulk crystal



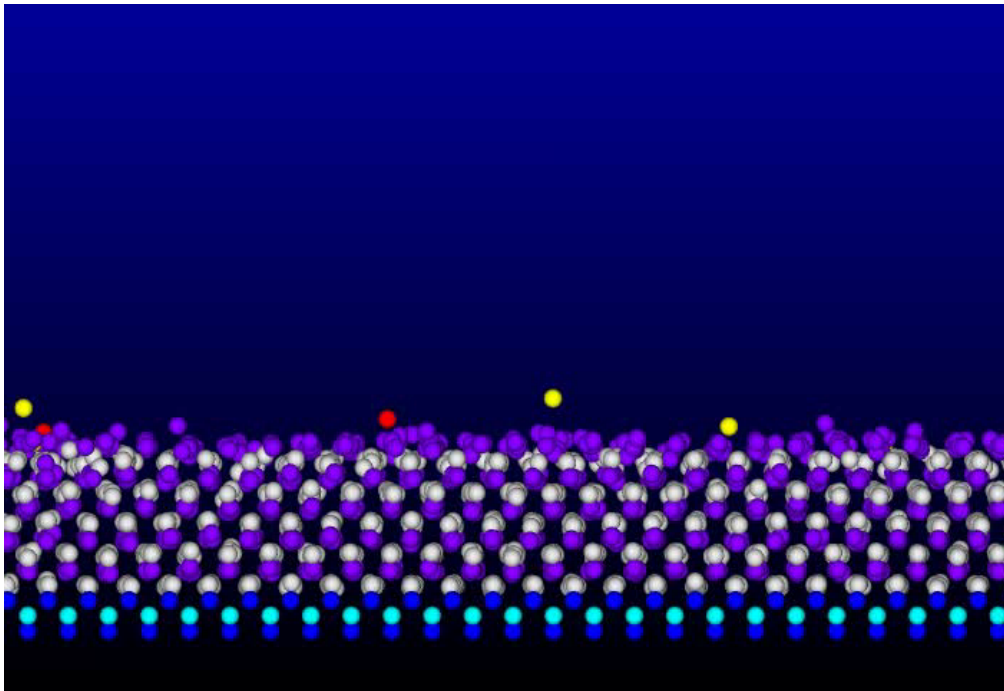
(b) thin film crystal



- ❑ Positions of atoms as a function of time from Newton's equations
- ❑ Thermal transport and phonon vibration calculations even without defects
- ❑ Computational mechanical testing simulations (elastic constants, strength)
- ❑ Defect properties (diffusion of point defects, dislocation energies, etc.)
- ❑ Structure from synthesis without any artificial assumptions

MD Growth Simulations

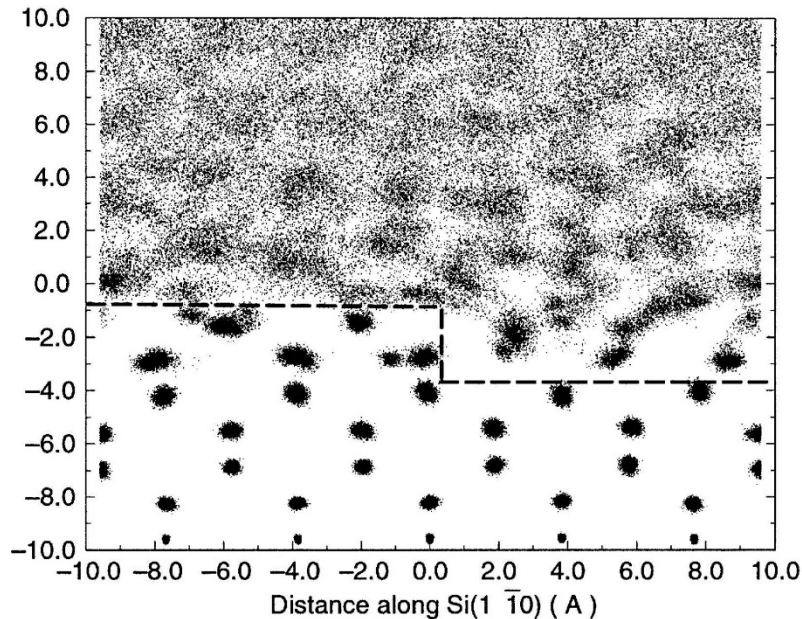
(CdTe on CdSe)



- ❑ Modern technologies rely on electronic devices based on thin film growth
- ❑ InGaN/GaN solid state lighting devices are currently limited by lattice mismatch defects
- ❑ CdTe/CdS photovoltaic devices are also limited by lattice mismatch defects
- ❑ These defects cannot be easily understood from experiments alone
- ❑ Growth simulations can reveal defect formation without any artificial assumptions
- ❑ Can rigorously test the model

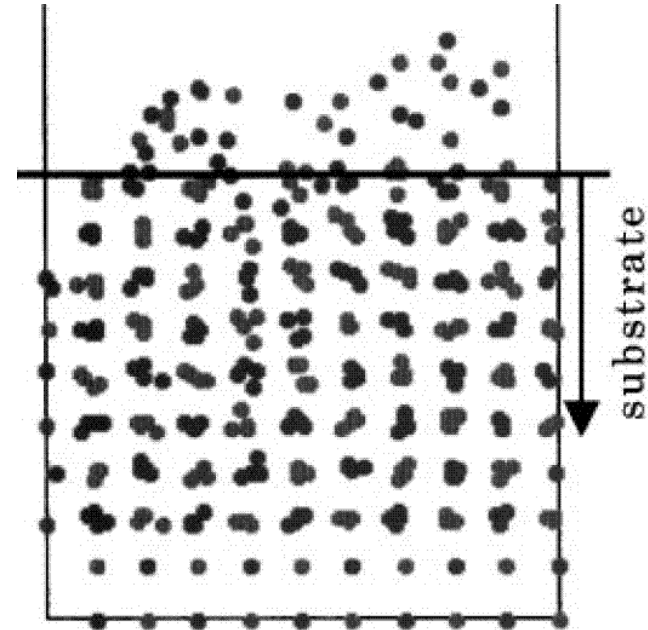
Challenges: Interatomic Potentials

CdTe on Si



J. Oh, and C. H. Grein, J. Cryst. Growth, 193, 241 (1998)

InAs on GaAs

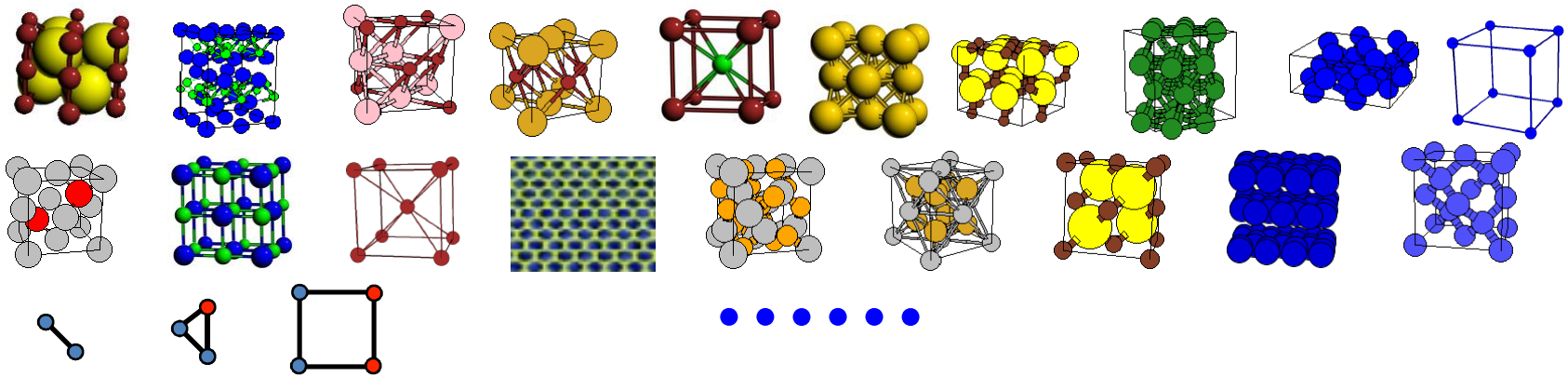


M. Nakamura, H. Fujioka, K. Ono, M. Takeuchi, T. Mitsui, and M. Oshima, J. Cryst. Growth, 209, 232(2000)

Because amorphous phase is the issue, fitting finite crystalline phases may never solve the problem

1. J. Tersoff, Phys. Rev. B, 39, 5566(1989) – for Si (amorphous growth, but can re-crystallize at 2200 K through bulk transformation)
2. P. A. Ashu, J. H. Jefferson, A. G. Cullis, W. E. Hagston, and C. R. Whitehouse, J. Cryst. Growth, 150, 176(1995). – for GaAs
3. R. Smith, Nucl. Instru. Meth. B, 67, 335(1992). – for GaAs

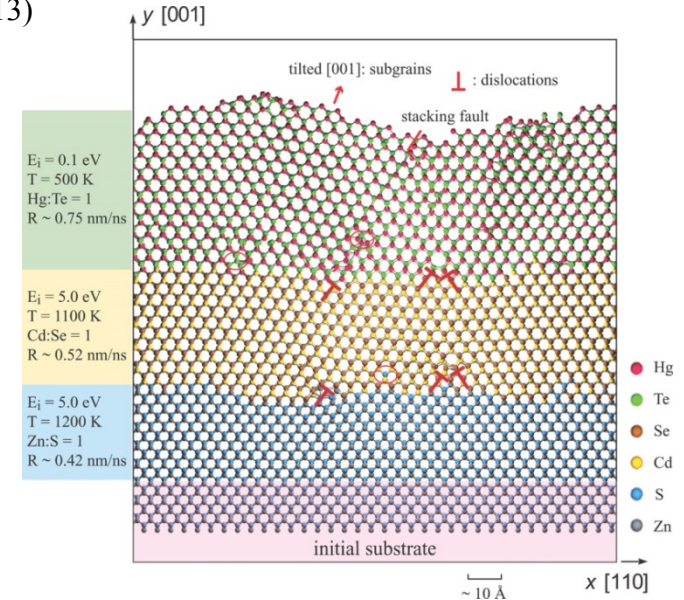
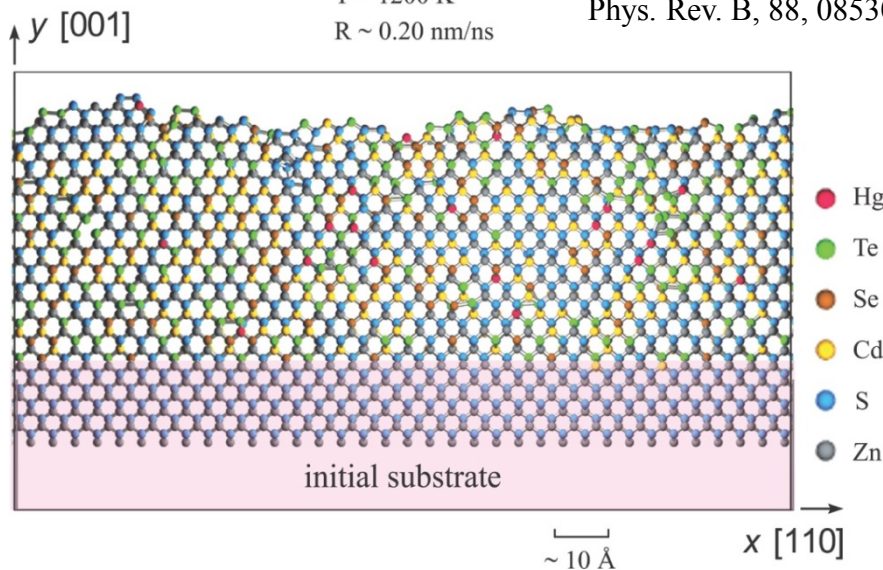
Towards Growth Simulation Enabling Potentials



A Zn-Cd-Hg-S-Se-Te Potential we developed

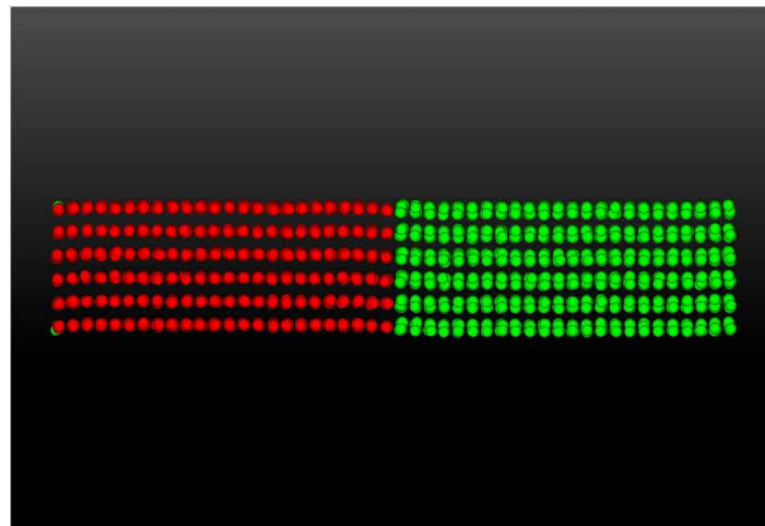
$E_i = 5.0$ eV
 $T = 1200$ K
 $R \sim 0.20$ nm/ns

X. W. Zhou, D. K. Ward, J. E. Martin, F. B. van Swol, J. L. Cruz-Campa, and D. Zubia,
 Phys. Rev. B, 88, 085309 (2013)

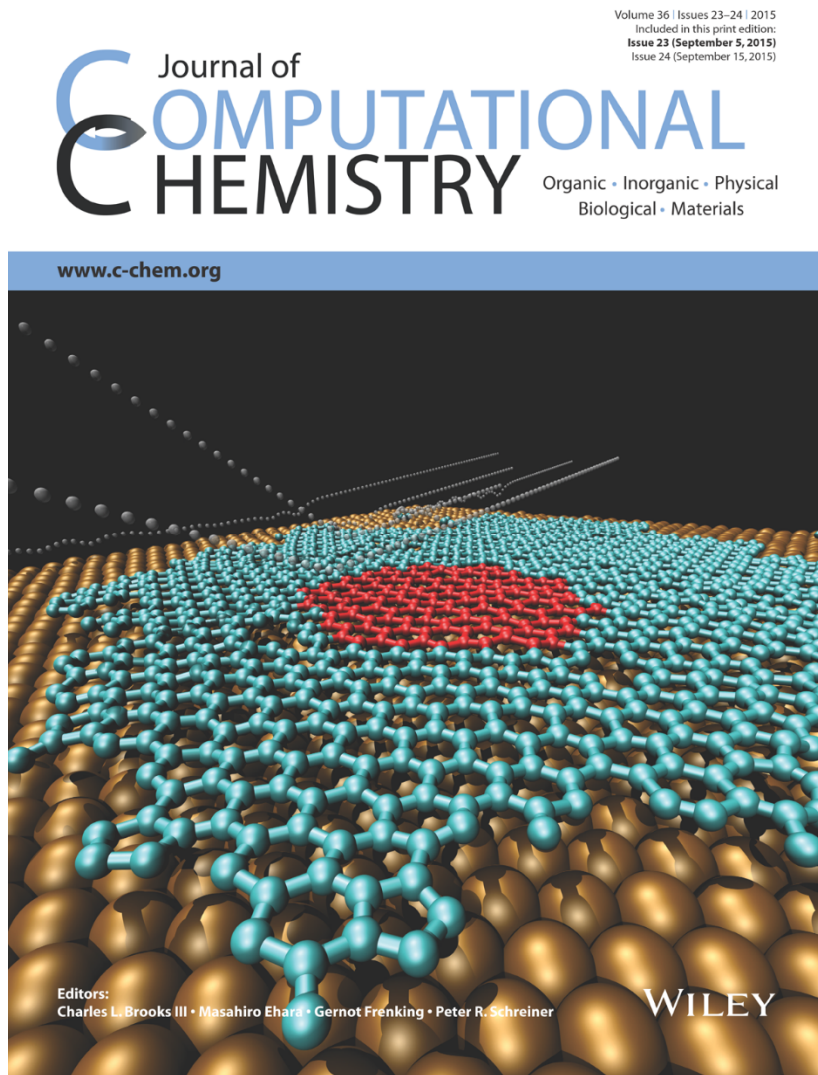
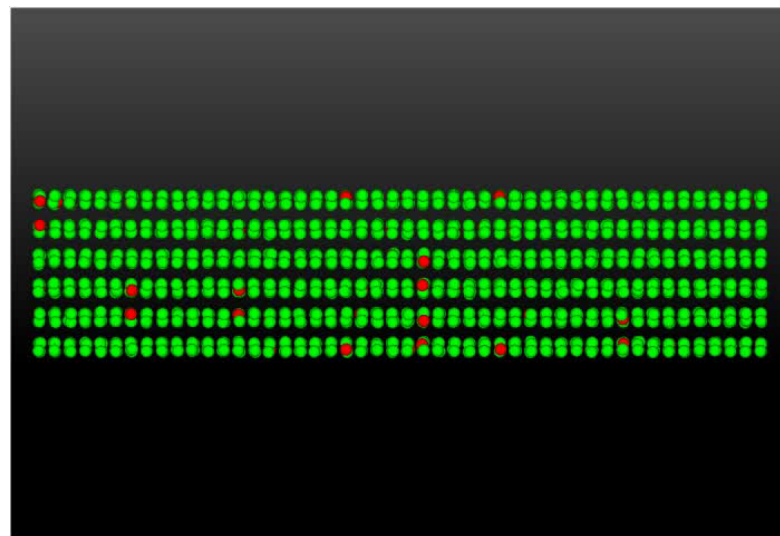


We Developed a Bond Order Potential to Enable Carbon Simulations

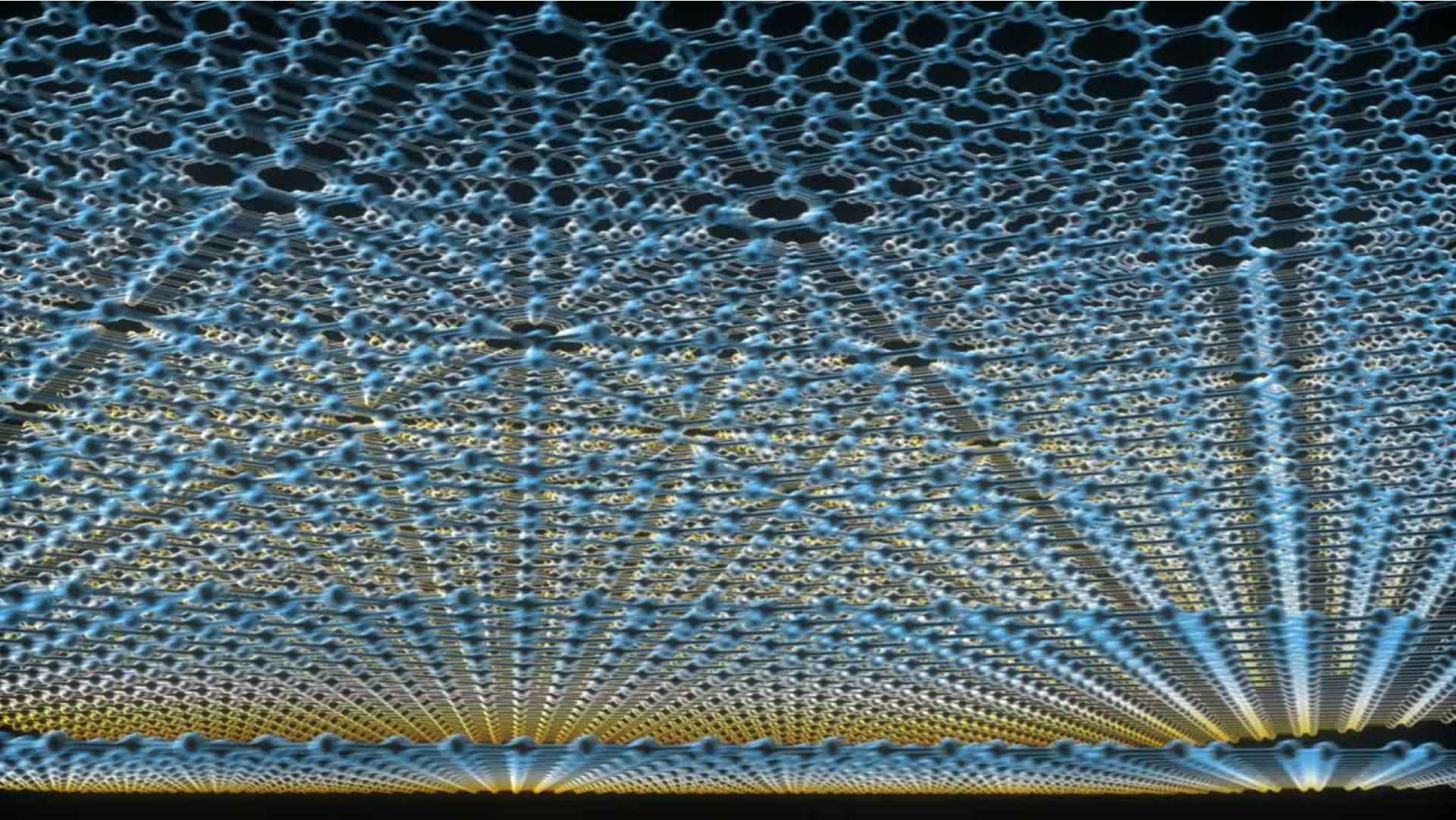
T = 2000 K, P = 0.6 Mbars (compressive)



T = 1600 K, P = -0.6 Mbars (tensile)



Graphene Growth Simulation



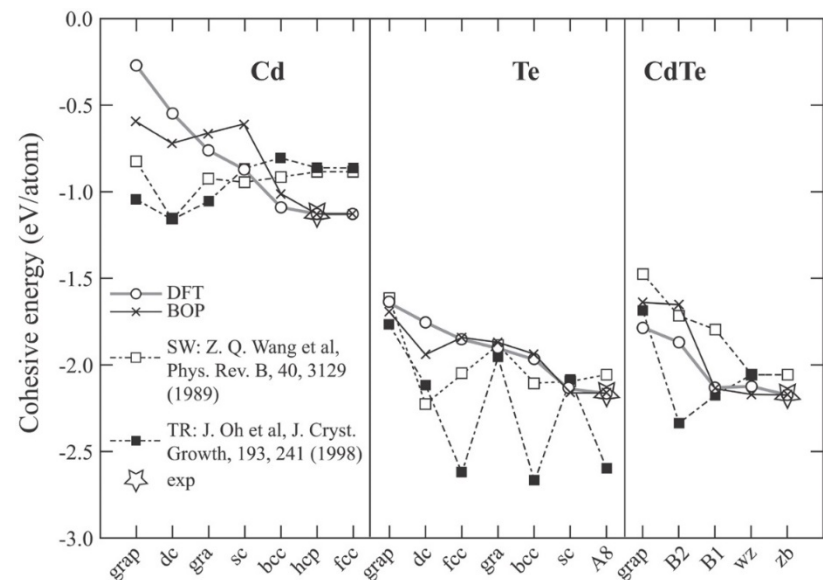
Solar Cell Example: CdTe/CdS

- ❑ CdTe/CdS solar cells have the low cost compared to other photovoltaic technologies, defect reduction further reduces cost
- ❑ Misfit dislocations are one of the primary defects
- ❑ BOP-based MD models have predicted dislocation-free CdTe/CdS solar cell structures

CdTe/CdS solar cells widely used

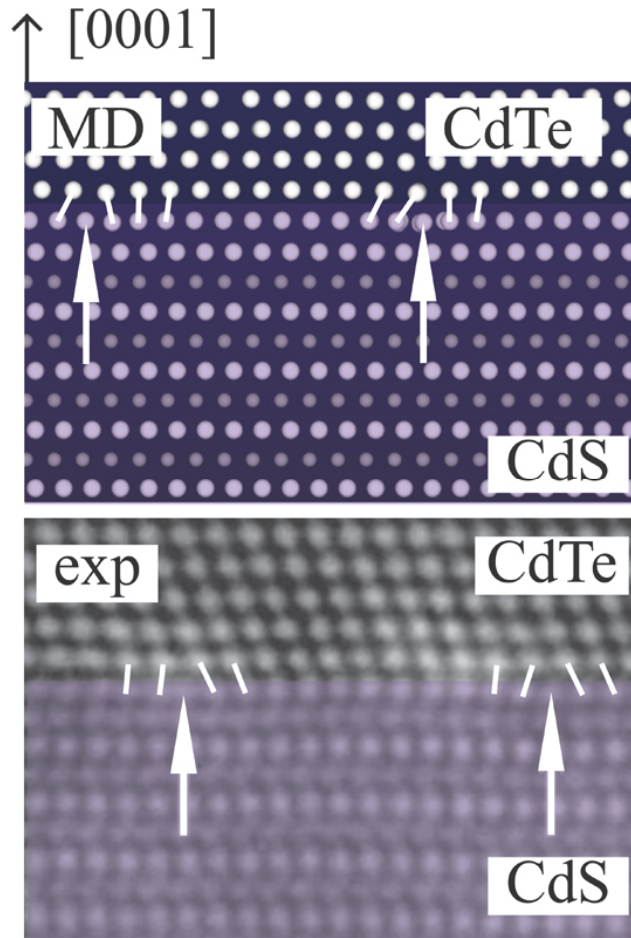


CdTe bond order potential captures DFT energy trends

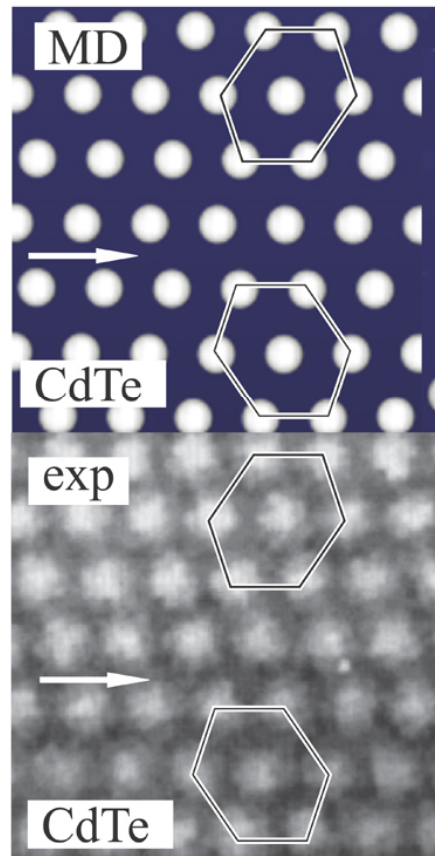


MD Validation I: CdTe/CdS Defects

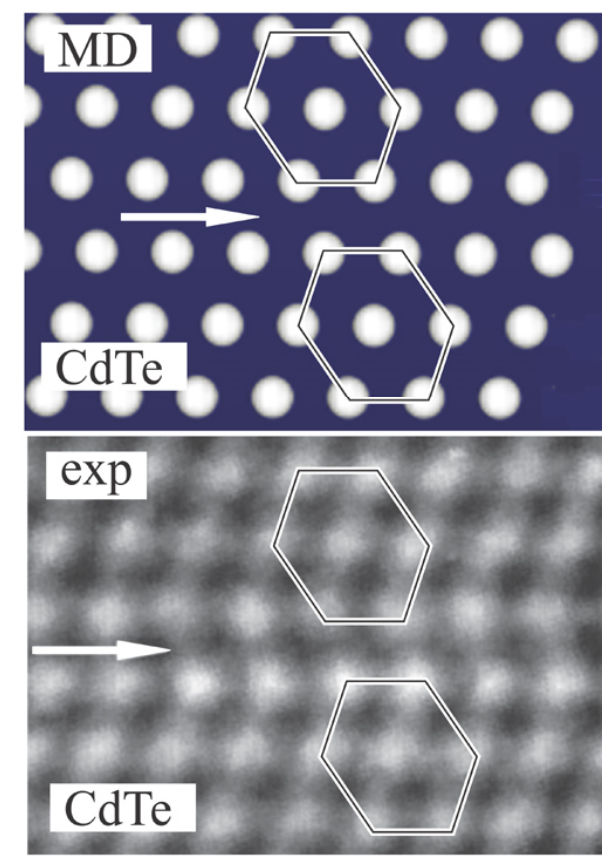
(a) Mismatch dislocations



(b) Twin



(c) Stacking fault



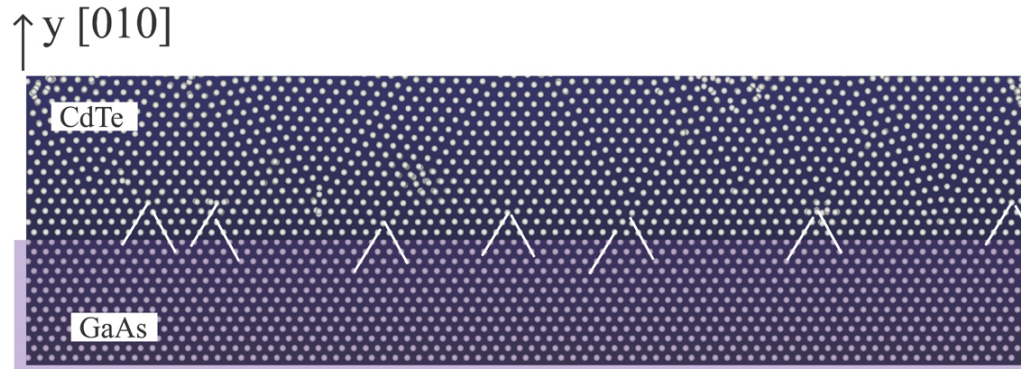
• $[11\bar{2}0]$

→ $[\bar{1}100]$

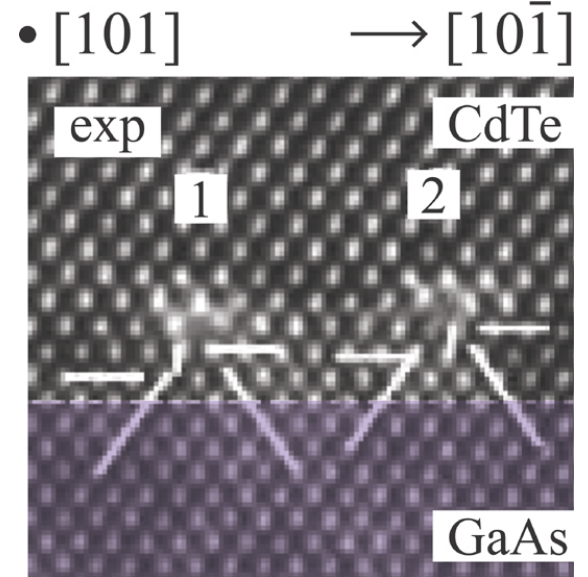
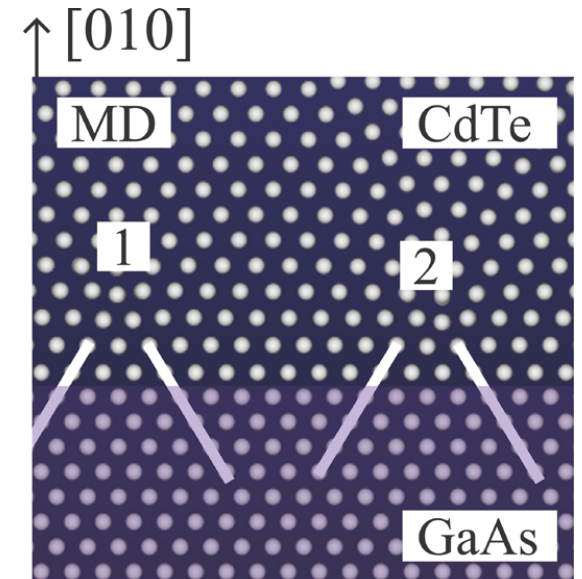
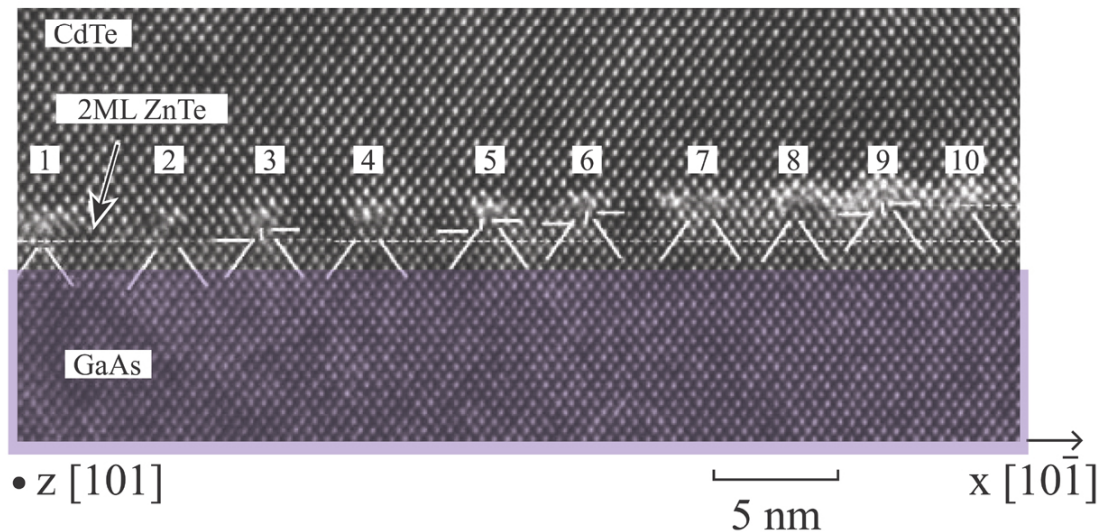
HRTEM from Y. Yan, R. G. Dhere, K. M. Jones, and M. M. Al-Jassim, J. Appl. Phys. 89, 5844 (2001)

MD Validation II: CdTe/GaAs Defects

(a) BOP simulation (only Cd and the approximate “Ga” atoms are shown)



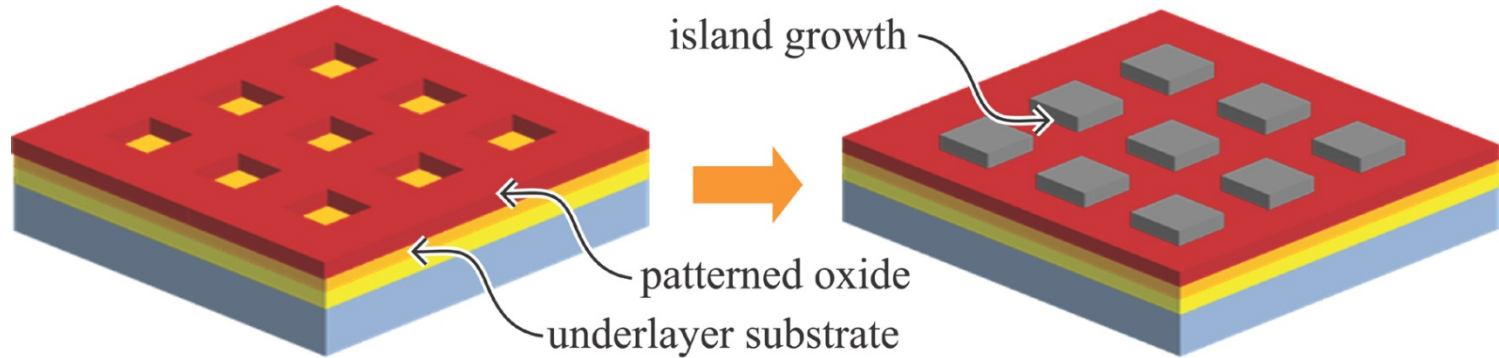
(b) HRTEM experimental image: S. Kret et al, Philo. Mag. 83, 231 (2003)



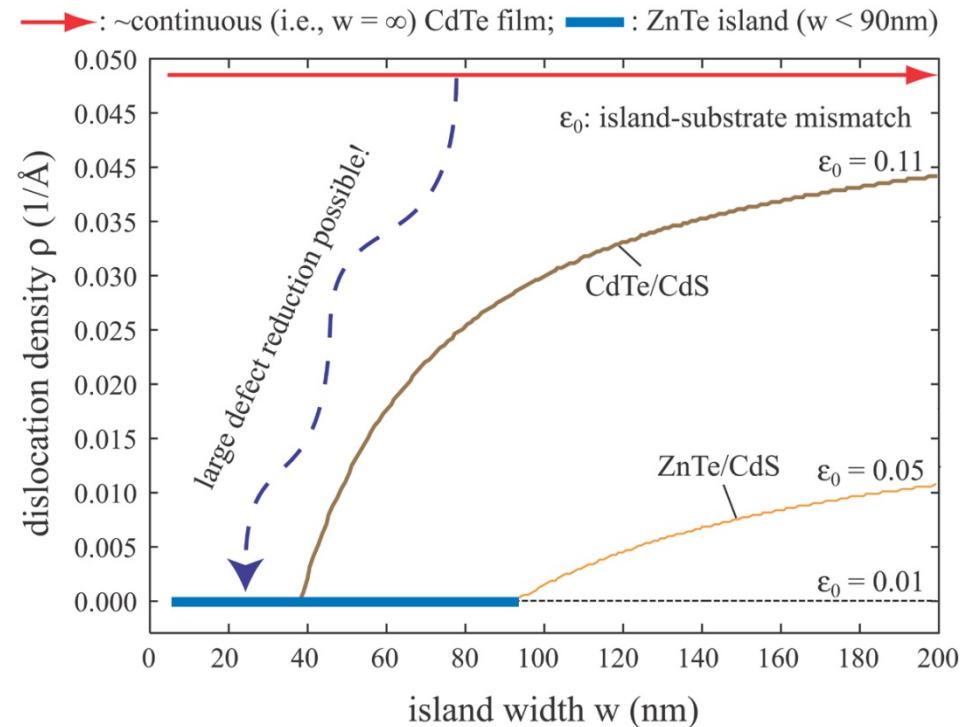
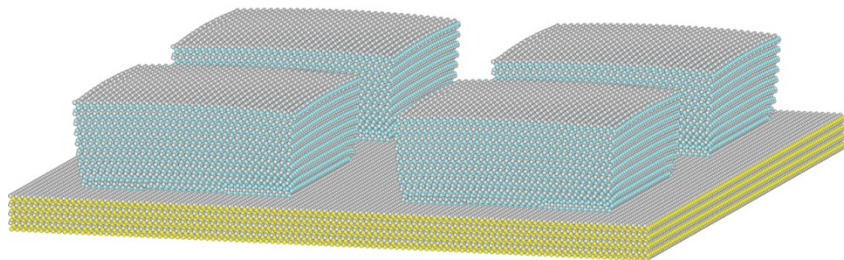
J. J. Chavez, D. K. Ward, B. M. Wong, F. P. Doty, J. L. Cruz-Campa, G. N. Nielson, V. P. Gupta, D. Zubia, J. McClure, and X. W. Zhou, Phys. Rev. B, 85, 245316 (2012)

Dislocation-Free CdTe/CdS Solar Cells

Modern nano technology:



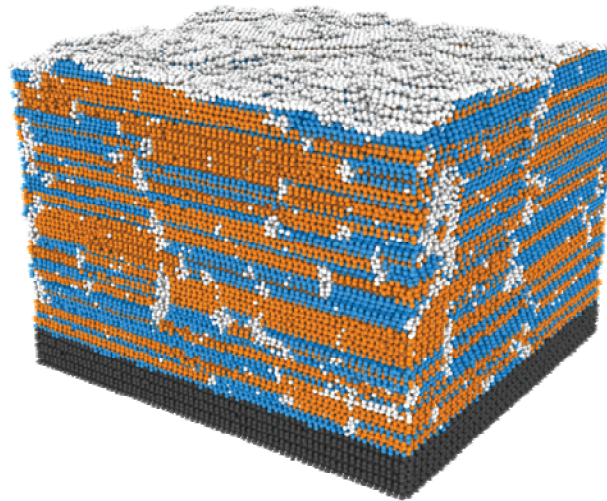
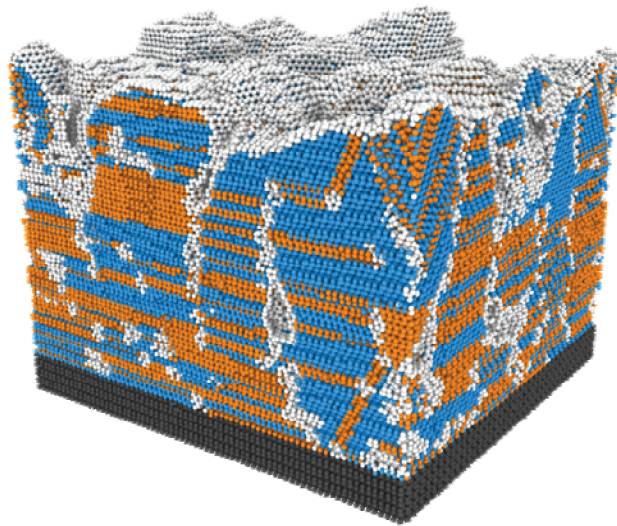
BOP simulation:



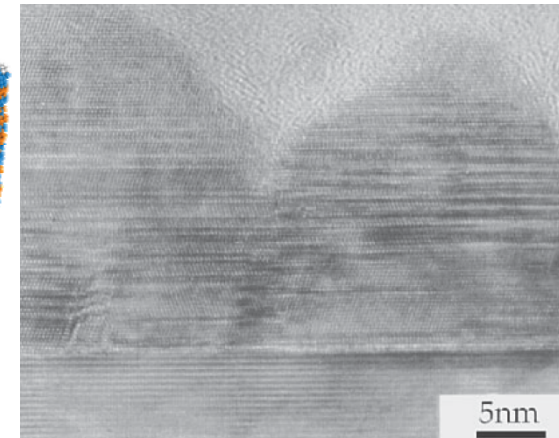
Solid State Lighting Example: GaN on (0001) GaN

(a) $T = 2000 \text{ K}$ ($T/T_m = 0.56$)

(b) $T = 2800 \text{ K}$ ($T/T_m = 0.78$)



■ Wurtzite ■ Zinc-Blende ■ Substrate □ Other

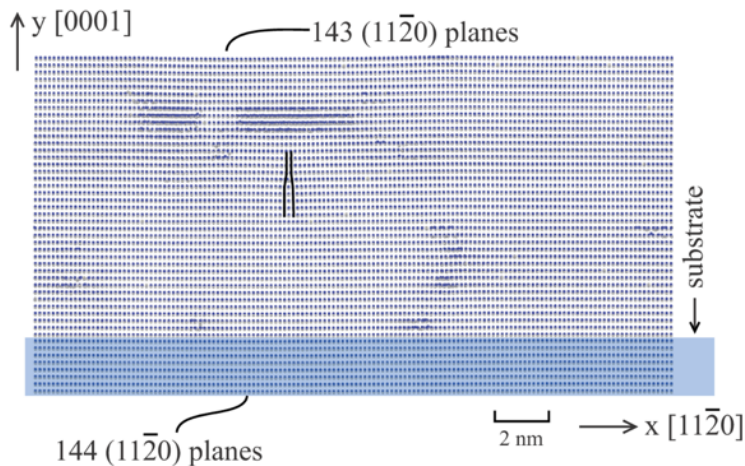


Experimental image from X. H. Wu et al, Appl. Phys. Lett., 68, 1372 (1996)

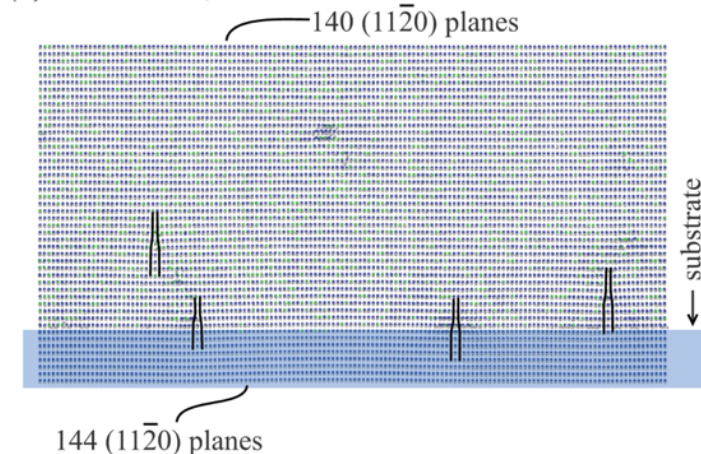
1. MD and experimental melting temperatures T_m are not the same. Use T/T_m
2. Significant polytypism is observed with the (0001) growth
3. Increasing temperature reduces surface roughness and associated defects

Misfit Dislocation in $\text{In}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$

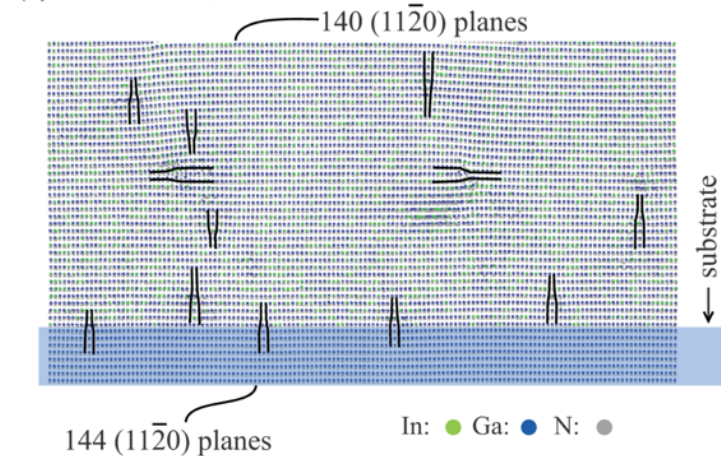
(a) $T^* = 3000 \text{ K}$, $x = 0.0$



(b) $T^* = 3000 \text{ K}$, $x = 0.3$



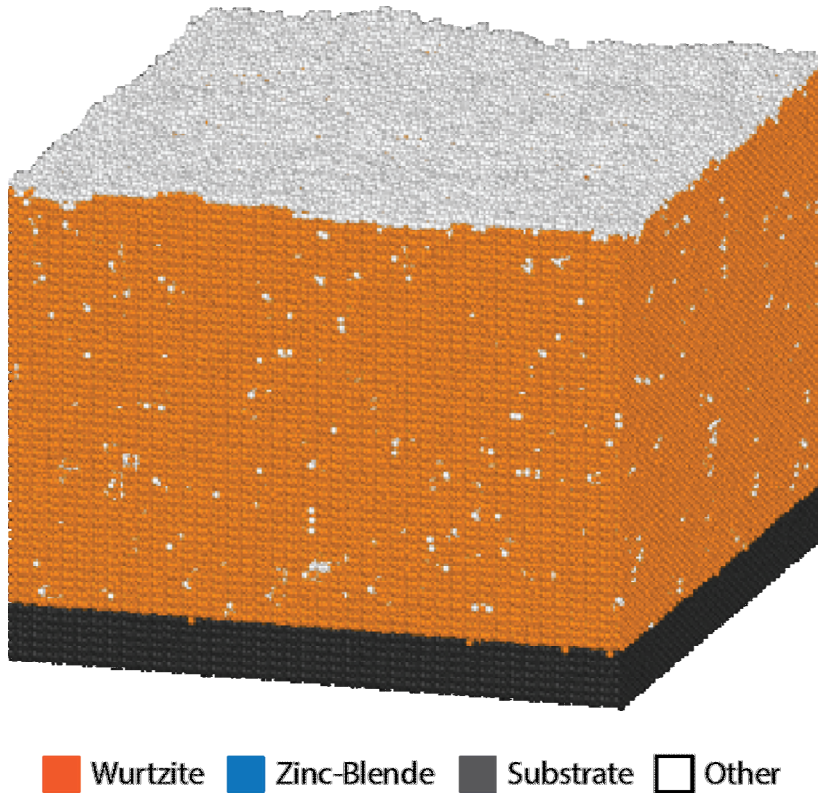
(c) $T^* = 2800 \text{ K}$, $x = 0.3$



1. Misfit dislocations in $\text{In}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$ films at (a) $x=0.0$, $T = 3000 \text{ K}$ ($T/T_m = 0.84$); (b) $x=0.3$, $T = 3000 \text{ K}$ ($T/T_m = 0.90$); and (c) $x=0.3$, $T = 2800 \text{ K}$ ($T/T_m = 0.84$). Atoms are colored by species
2. Some dislocations are kinetically trapped. The number of misfit dislocations equals difference of number of planes between top and bottom surfaces

$\text{In}_{0.4}\text{Ga}_{0.6}\text{N}$ on (11-20) GaN

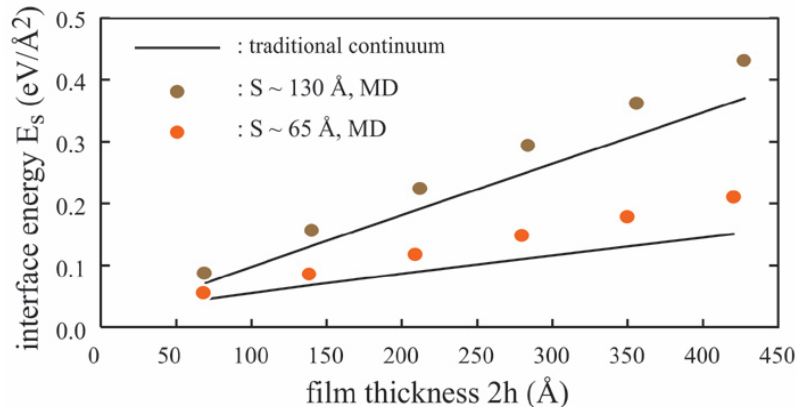
GaN on a (11-20) GaN at 2800 K ($T/T_m = 0.78$)



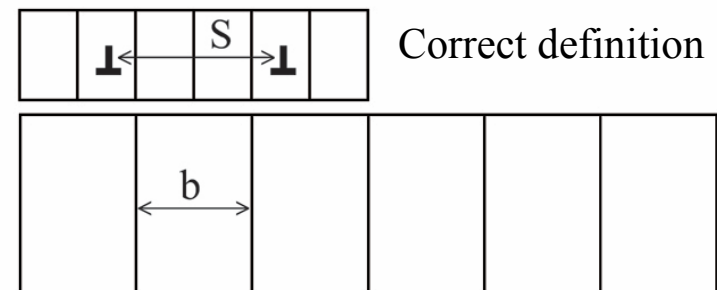
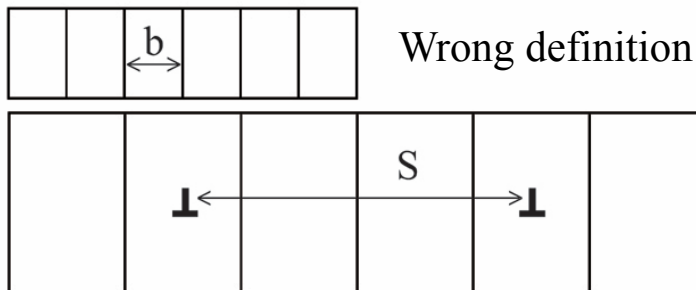
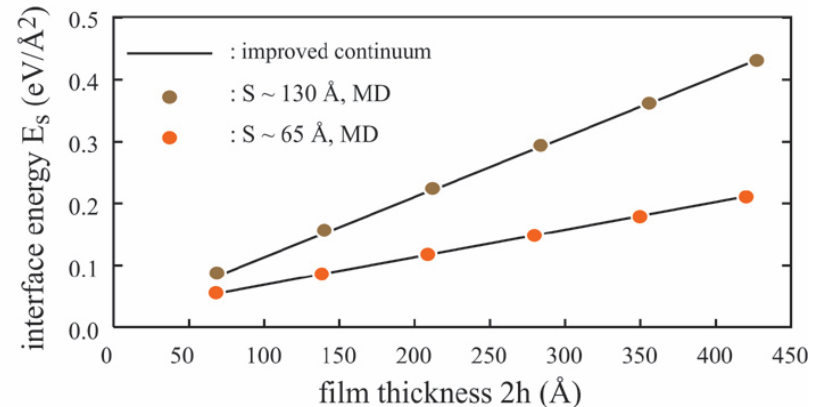
1. Formation of polytypism is due to the ABCABC... stacking, where atoms can occupy either B or C sites on a given plane
2. To test the polytypism formation mechanism, growth is simulated on (11-20) plane where the stacking sequence is ABAB...
3. Indeed, the polytypism is eliminated on the (11-20) growth

MD Validation of Misfit Dislocation Theory

(a) Traditional misfit dislocation theory



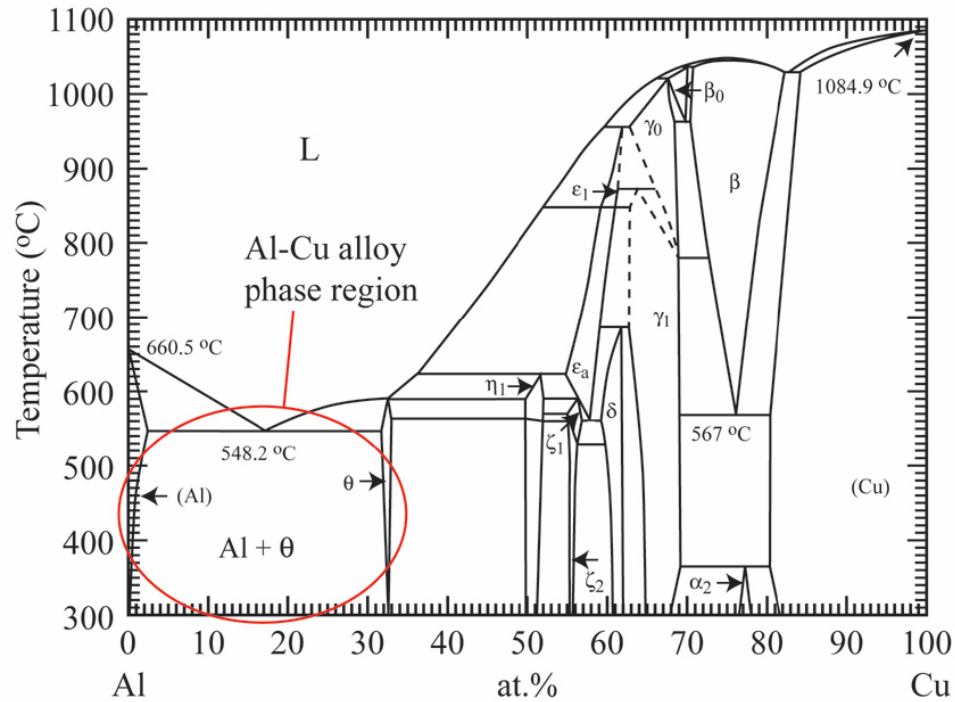
(b) MD guided improved misfit dislocation theory



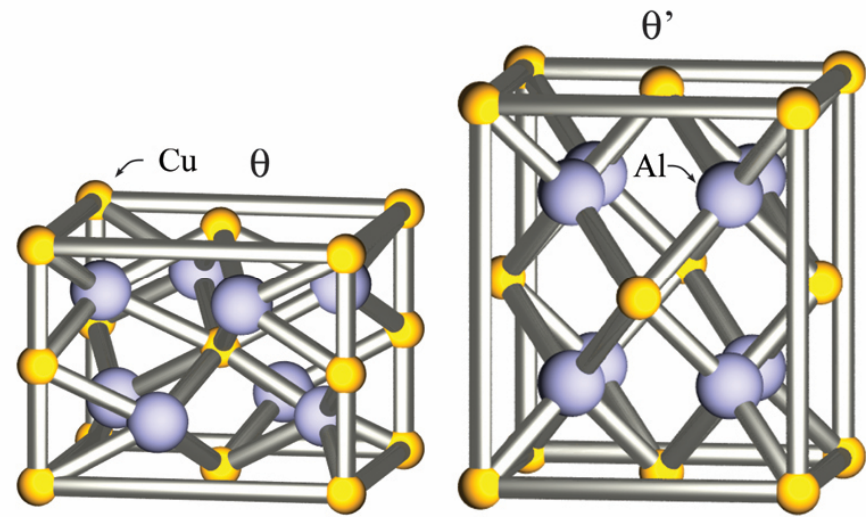
- Continuum misfit dislocation theory has been widely used since 1980's
- MD simulations revealed that traditional continuum misfit dislocation theory is incorrect in the definition of dislocation Burgers vector and dislocation spacing
- This example indicates that MD can “validate” and improve continuum models

Al-Cu Bond Order Potential

(a) Al-Cu phase diagram

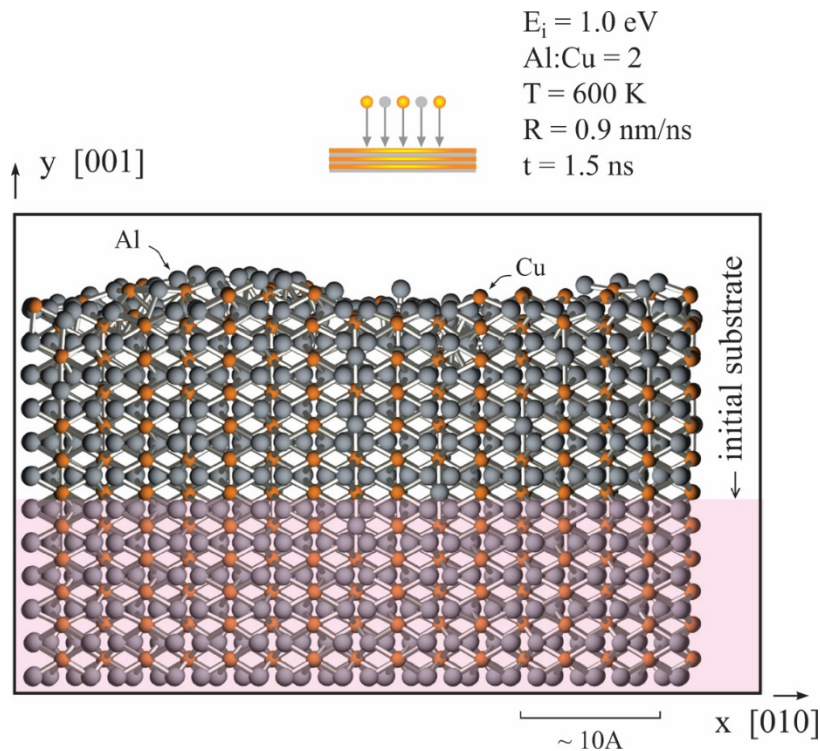


(b) crystal structure of the θ and θ' phases

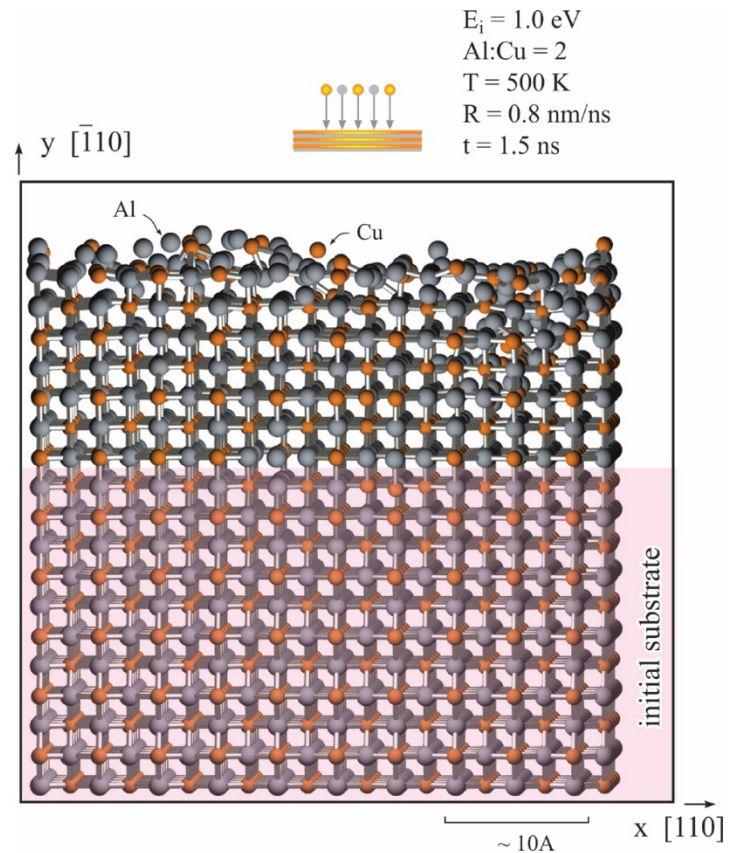


Growth Simulation Tests on BOP

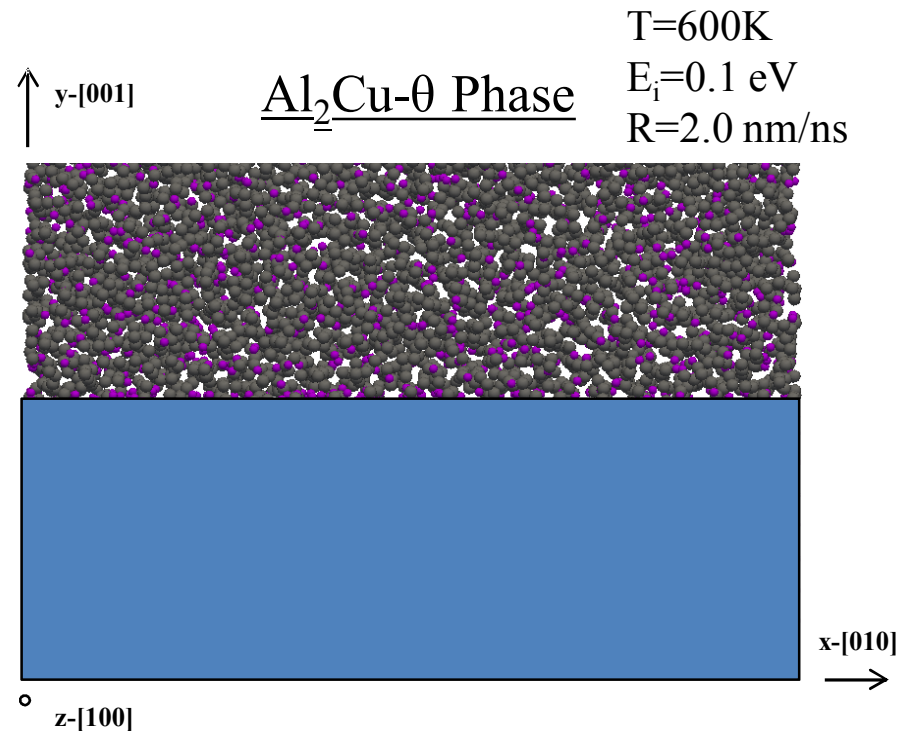
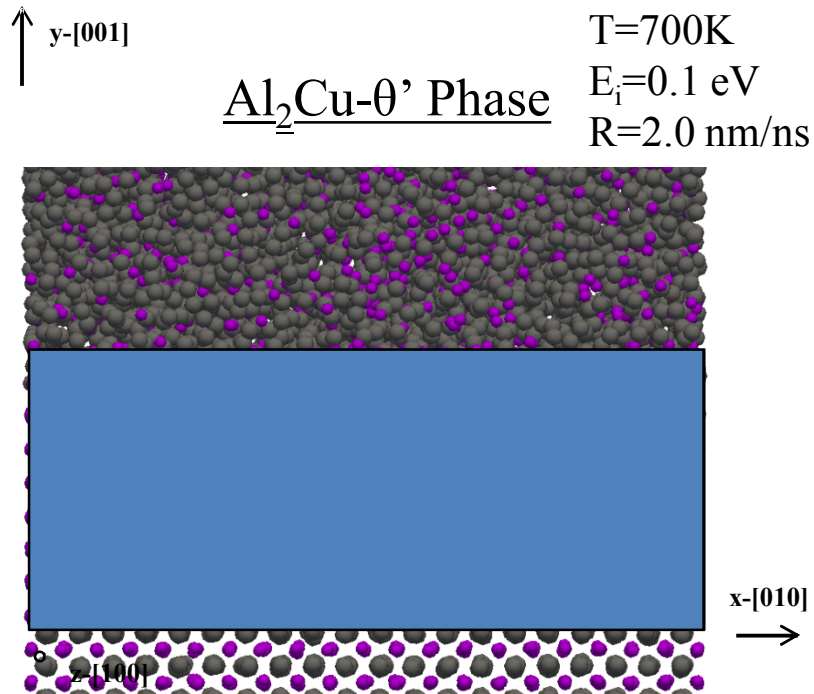
Crystalline growth of θ -Al₂Cu



Crystalline growth of θ' -Al₂Cu



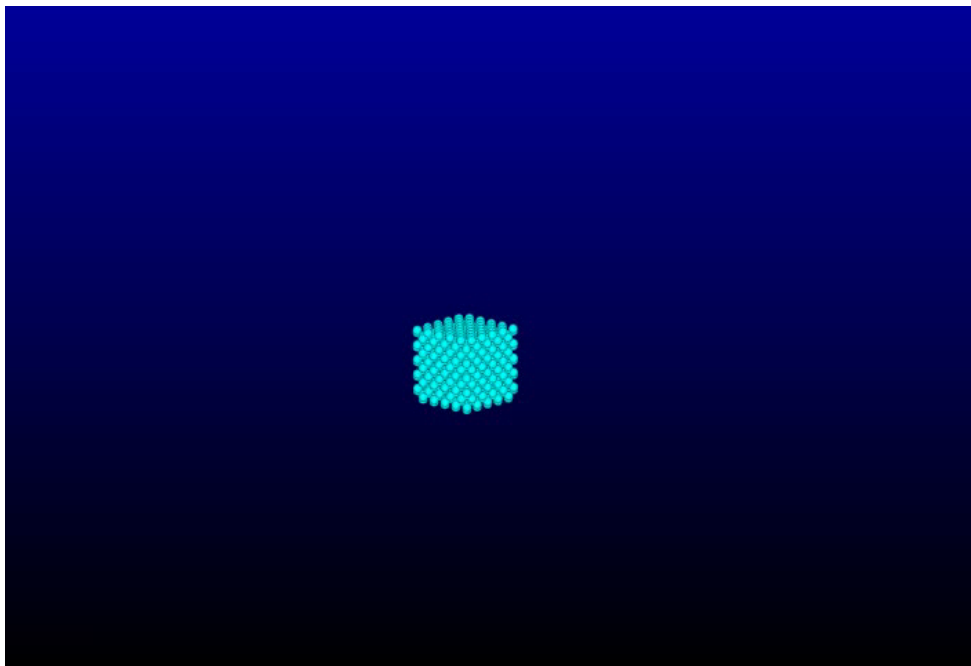
Growth Simulation Tests on the Previously Best Potential (Mishin et al)



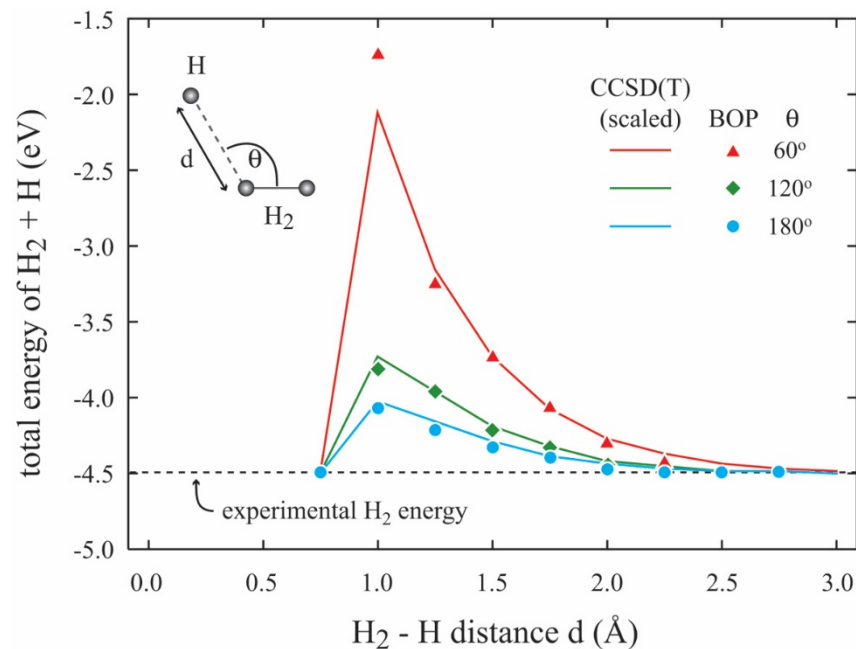
ADP: F. Apostol and Y. Mishin, PRB 83, 054116 (2011)

Chemical Reaction Simulations Using Our Bond Order Potential (BOP)

Hydrogen crystal to H₂ gas

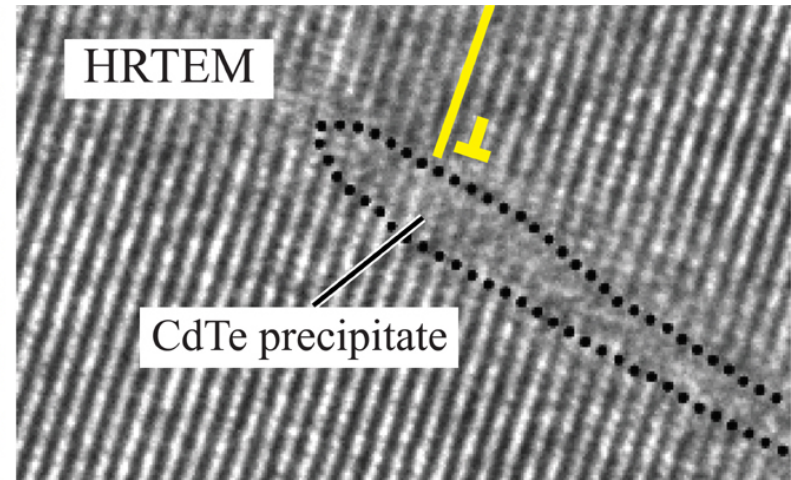
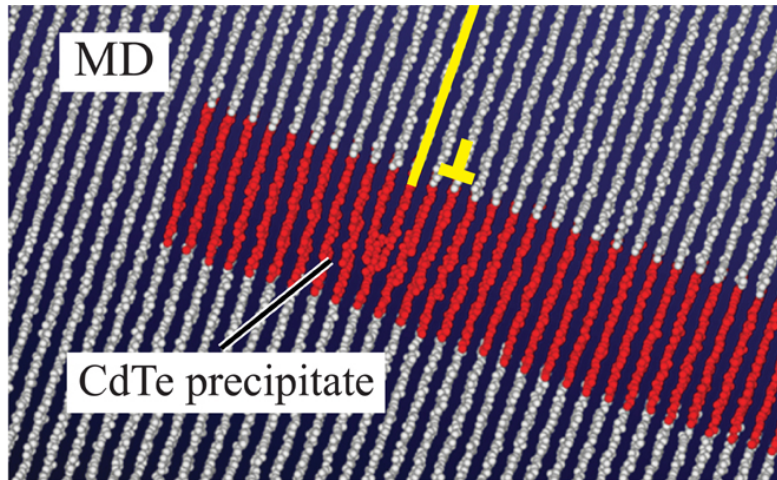


H₂+H→H+H₂ energy profiles

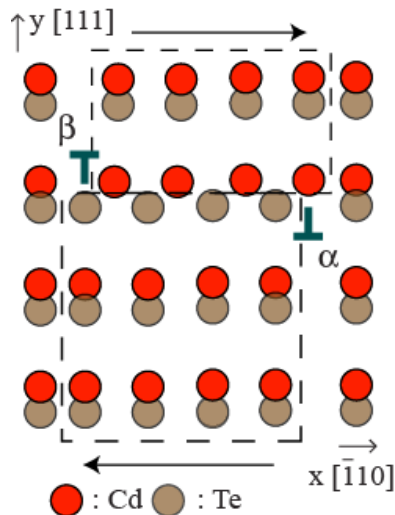


The BOP we developed has captured the $\text{H}_2 + \text{H} \rightarrow \text{H} + \text{H}_2$ reaction about 1-2 years ago, paper has been published: X. W. Zhou, D. K. Ward, M. Foster, J. A. Zimmerman, J. Mater. Sci., 50, 2859 (2015).

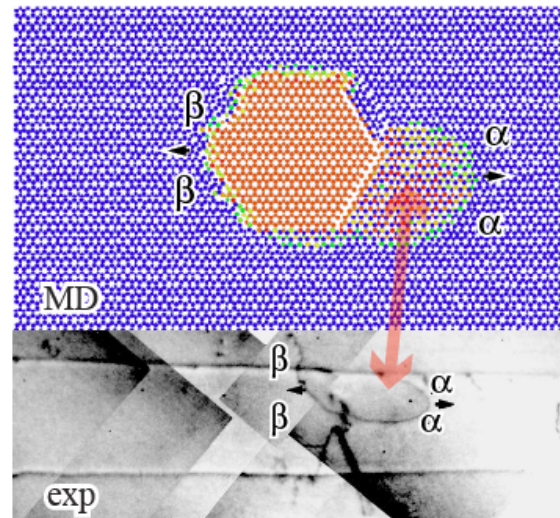
Dislocation Behavior in Semiconductor Compounds: Radiation Detecting $\text{Cd}_x\text{Zn}_{1-x}\text{Te}$



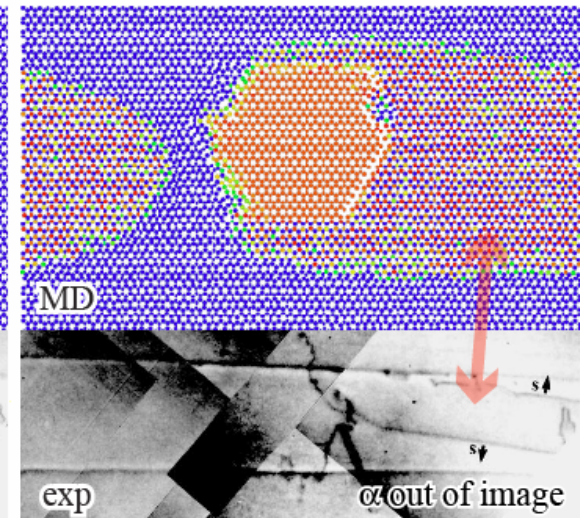
(a) α and β dislocations



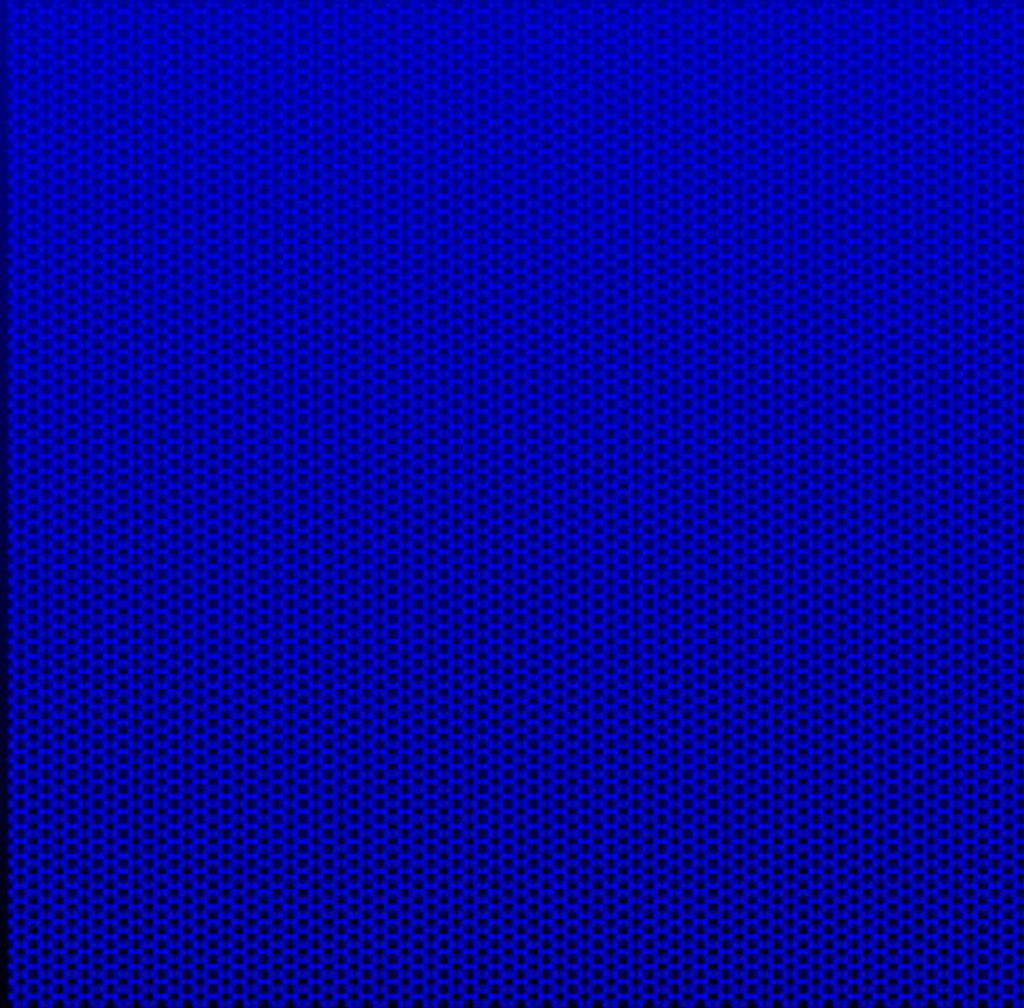
(b) initial configuration



(c) later configuration



α and β Dislocation Mobility



Conclusions

MD simulations have impacted:

- ☐ Graphene growth
- ☐ Giant magnetoresistive multilayers
- ☐ CdTe/CdS solar cell films
- ☐ $\text{In}_x\text{Ga}_{1-x}\text{N}/\text{GaN}$ solid state lighting films
- ☐ Misfit dislocation theory
- ☐ Research on Al-Cu alloys
- ☐ Chemical reactions between H_2 and surfaces
- ☐ Radiation detecting $\text{Cd}_x\text{Zn}_{1-x}\text{Te}$

Thank You ...